

<u>HS96</u>	<u>Description</u>	<u>Base rate</u>	<u>Bound rate</u>	<u>Implementation*</u>	<u>Present concession established</u>	<u>Concession first incorporated in a GATT Schedule</u>	<u>Earlier INRs</u>	<u>ODCs</u>
854381	--Proximity cards and tags	116.7	0	2005	WT/Let			0
854389	--Other							
ex854389	---Electrical machines with translation or dictionary functions	116.7	0	2005	WT/Let			0
ex854389	Pattern generating apparatus of a kind used for producing masks or reticles from photoresist coated substrates	116.7	0	2000	WT/Let			0
854390	-Parts							
ex854390	--Parts of ion implanters for doping semiconductor materials	116.7	0	2000	WT/Let			0
ex854390	Parts of apparatus for wet etching, developing, stripping or cleaning semiconductor wafers and flat panel displays.	116.7	0	2000	WT/Let			0
ex854390	Parts and accessories of pattern generating apparatus of a kind used for producing masks or reticles from photoresist coated substrates	116.7	0	2000	WT/Let			0
ex854390	Printed circuit assemblies for proximity cards and tags, printed circuit assemblies for electrical machines with translation or dictionary functions	116.7	0	2005	WT/Let			0
8544	Insulated (including enamelled or anodised) wire, cable (including coaxial cable) and other insulated electric conductors, whether or not fitted with connectors; optical fibre cables, made up of individually sheathed fibres, whether or not assembled with electric conductors or fitted with connectors.							
854441	--Other electric conductors, for a voltage not exceeding 80 V							
854441	--Fitted with connectors							

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ex854441	---Other electric conductors, for a voltage not exceeding 80 V, fitted with connectors, of a kind used for telecommunications	90	0	2005	WT/Let			0
854449	--Other							
ex854449	---Other electric conductors, for a voltage not exceeding 80 V, not fitted with connectors, of a kind used for telecommunications	90	0	2005	WT/Let			0
854451	-Other electric conductors, for a voltage exceeding 80 V but not exceeding 1,000 V.							
854451	--Fitted with connectors							
ex854451	---Other electric conductors, for a voltage exceeding 80 V but not exceeding 1000 V, fitted with connectors, of a kind used for telecommunications	90	0	2005	WT/Let			0
854470	-Optical fibre cables	110	0	2005	WT/Let			0
9009	Photo-copying apparatus incorporating an optical system or of the contact type and thermo-copying apparatus.							
900911	-Electrostatic photo-copying apparatus:							
	--Operating by reproducing the original image directly onto the copy (direct process)	110	0	2005	WT/Let			0
900921	-Other photo-copying apparatus:							
	--Incorporating an optical system	110	0	2005	WT/Let			0
900990	-Parts and accessories	110	0	2005	WT/Let			0

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9010	Apparatus and equipment for photographic (including cinematographic) laboratories (including apparatus for the projection or drawing of circuit patterns on sensitised semiconductor materials), not specified or included elsewhere in this Chapter; negatoscopes; projection screens.							
901041	-Apparatus for the projection or drawing of circuit patterns on sensitised semiconductor materials: --Direct write-on-wafer apparatus	110	0	2000	WT/Let			0
901042	--Step and repeat aligners	110	0	2000	WT/Let			0
901049	--Other	110	0	2000	WT/Let			0
901090	-Parts and accessories							
ex901090	--Parts and accessories of the apparatus of Headings No 9010 41 to 9010 49	110	0	2000	WT/Let			0
9011	Compound optical microscopes, including those for photomicrography, cinephotomicrography or microprojection.							
901110	- Stereoscopic microscopes.							
ex901110	Optical stereoscopic microscopes fitted with equipment specially designed for the handling and transport of semiconductor wafers or reticles.	70	0	2000				0
901120	- Other microscopes, for photomicrography, cinephotomicrography or microprojection.							

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ex901120	Photomicrographic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles.	70	0	2000			0	
901190	- Parts and accessories.							
ex901190	Parts and accessories of optical stereoscopic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles.	70	0	2000			0	
ex901190	Parts and accessories of photomicrographic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles.	70	0	2000			0	
9012	Microscopes other than optical microscopes; diffraction apparatus.							
901210	- Microscopes other than optical microscopes and diffraction apparatus.							
ex901210	Electron beam microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles.	70	0	2000			0	
901290	- Parts and accessories.							
ex901290	Parts and accessories of electron beam microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles.	70	0	2000			0	

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9017	Drawing, marking out or mathematical calculating instruments (for example, drafting machines, pantographs, protractors, drawing sets, slide rules, discalculators); instruments for measuring length, for use in the hand (for example, measuring rods and tapes, micrometers, calipers), not specified or included elsewhere in this Chapter.							
ex901710	Drafting machines of heading no. 9017.	40	0	2005				0
901720	- Other drawing, marking-out or mathematical calculating instruments.							
ex901720	Pattern generating apparatus of a kind used for producing masks or reticles from photoresist coated substrates.	40	0	2000				0
ex901720	Drawing machines of heading no. 9017.	40	0	2005				0
901790	- Parts and accessories.							
ex901790	Parts and accessories for pattern generating apparatus of a kind used for producing masks or reticles from photoresist coated substrates.	110	0	2000				0
ex901790	Printed circuit assemblies for drafting machines of heading no.90.17, printed circuit assemblies for drawing machines of heading no.90.17	110	0	2005	WT/Let			0
9026	Instruments and apparatus for measuring or checking the flow, level, pressure or other variables of liquids or gases (for example, flow meters, level gauges, manometers, heat meters), excluding instruments and apparatus of heading No. 90.14, 90.15, 90.28 or 90.32.							

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902610	-For measuring or checking the flow or level of liquids	40	0	2005	WT/Let			0
902620	-For measuring or checking pressure	40	0	2005	WT/Let			0
902680	-Other instruments or apparatus	40	0	2005	WT/Let			0
902690	-Parts and accessories	110	0	2003	WT/Let			0
9027	Instruments and apparatus for physical or chemical analysis (for example, polarimeters, refractometers, spectrometers, gas or smoke analysis apparatus); instruments and apparatus for measuring or checking viscosity, porosity, expansion, surface tension or the like; instruments and apparatus for measuring or checking quantities of heat, sound or light (including exposure meters); microtomes.							
902720	-Chromatographs and electrophoresis instruments	35	0	2005	WT/Let		EC/Japan/US0	
902730	-Spectrometers, spectrophotometers and spectrographs using optical radiations (UV, visible, IR)	35	0	2005	WT/Let		EC/Japan/US0	
902750	-Other instruments and apparatus using optical radiations (UV, visible, IR)	35	0	2005	WT/Let		EC/Japan/US0	
902780	-Other instruments and apparatus	35	0	2005	WT/Let		EC/Japan/US0	
902790	-Microtomes, parts and accessories	35	0	2003	WT/Let		EC/Japan/US0	
ex902790	--Parts and accessories of products of heading 9027, other than for gas or smoke analysis apparatus and microtomes	35	0	2003	WT/Let		EC/Japan/US0	

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9030	Oscilloscopes, spectrum analysers and other instruments and apparatus for measuring or checking electrical quantities, excluding meters of heading No. 90.28; instruments and apparatus for measuring or detecting alpha, beta, gamma, X-ray, cosmic or other ionising radiations.							
903040	-Other instruments and apparatus, specially designed for telecommunications (for example, cross-talk meters, gain measuring instruments, distortion factor meters, psophometers)	70	0	2005	WT/Let		0	
903082	-Other instruments and apparatus: --For measuring or checking semiconductor wafers or devices	40	0	2000	WT/Let		0	
903090	-Parts and accessories							
ex903090	--Parts and accessories of instruments and apparatus for measuring or checking semiconductor wafers or devices	40	0	2000	WT/Let		0	
ex903090	--Parts of instruments and appliances for measuring or checking semiconductor wafers or devices	40	0	2000	WT/Let		0	
9031	Measuring or checking instruments, appliances and machines, not specified or included elsewhere in this Chapter; profile projectors.							
903141	-Other optical instruments and appliances: --For inspecting semiconductor wafers or devices or for inspecting photomasks or reticles used in manufacturing semiconductor devices	40	0	2000	WT/Let		0	
903149	--Other							

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ex903149	--Optical instruments and appliances for measuring surface particulate contamination on semiconductor wafers	40	0	2000	WT/Let			0
903190	-Parts and accessories							
ex903190	--Parts and accessories of optical instruments and appliances for inspecting semiconductor wafers or devices or for inspecting masks, photomasks or reticles used in manufacturing semiconductor devices	40	0	2000	WT/Let			0
ex903190	--Parts and accessories of optical instruments and appliances for measuring surface particulate contamination on semiconductor wafers	40	0	2000	WT/Let			0
702000	Other articles of glass							
ex702000	Quartz reactor tubes and holders designed for insertion into diffusion and oxidation furnaces for production of semi conductor wafers	110	0	2000	WT/Let			0
9013	Liquid crystal devices not constituting articles provided for more specifically in other headings, lasers, other than laser diodes; other optical appliances and instruments, not specified or included elsewhere in this chapter							
901380	Other devices, appliances and instruments							
ex901380	Liquid crystal devices	22	0	2000	WT/Let			0
901390	Parts and accessories							
ex901390	Parts and accessories of LCD	22	0	2000	WT/Let			0

HS96

Description

Base rate Bound rate Implementation\*

Present  
concession  
established INR

Concession first  
incorporated in a  
GATT Schedule Earlier INRs ODCs

\* The changes in the Tariffs will be made effective from 1 March since normally tariff changes are given effect to from 1 March on the basis of the Budget presented to the Parliament on the last day of February

## India

26 March 1997

With respect to any product described in or for Attachment B to the Annex to the Ministerial Declaration on Trade in Information Technology Products (WT/MIN(96)/16), to the extent not specifically provided for in this Schedule, the customs duties on such product, as well as any other duties and charges of any kind (within the meaning of Article II:1(b) of the General Agreement on Tariffs and Trade 1994), shall be bound and eliminated, as set forth in paragraph 2(a) of the Annex to the Declaration, wherever the product is classified.

### Description

### HS

Quartz reactor tubes and holders designed for insertion into diffusion and oxidation furnaces for production of semiconductor wafers	701710,702000
Chemical vapor deposition apparatus for semiconductor production	841989
Parts of chemical vapor deposition apparatus for semiconductor production	841990
Apparatus for stripping or cleaning semiconductor wafers	845691
Lasercutters for cutting contacting tracks in semiconductor production by laser beam	845699
Machines for sawing monocrystal semiconductor boules into slices, or wafers into chips	846410
Parts for machines for sawing monocrystal semiconductor boules into slices, or wafers into chips	846691
Parts of dicing machines for scribing or scoring semiconductor wafers	846691
Parts of lasercutters for cutting contacting tracks in semiconductor production by laser beam	846693
Parts of apparatus for stripping or cleaning semiconductor wafers	846693
Encapsulation equipment for assembly of semiconductors	847710
Parts of encapsulation equipment	847790
Automated machines for transport, handling and storage of semiconductor wafers, wafer cassettes, wafer boxes and other material for semiconductor devices	847950
Apparatus for physical deposition by sputtering on semiconductor wafers	847989
Apparatus for wet etching, developing, stripping or cleaning semiconductor wafers and flat panel displays	847989
Die attach apparatus, tape automated bonders, and wire bonders for assembly of semiconductors	847989
Encapsulation equipment for assembly of semiconductors	847989
Machines for bending, folding and straightening semiconductor leads	847989

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<u>Description</u>	<u>HS</u>
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Physical deposition apparatus for semiconductor production	847989
Spinners for coating photographic emulsions on semiconductor wafers	847989
Part of apparatus for physical deposition by sputtering on semiconductor wafers	847990
Parts for die attach apparatus, tape automated bonders, and wire bonders for assembly of semiconductors	847990
Parts for spinners for coating photographic emulsions on semiconductor wafers	847990
Parts of apparatus for wet etching, developing, stripping or cleaning semiconductor wafers and flat panel displays	847990
Parts of automated machines for transport, handling and storage of semiconductor wafers, wafer cassettes, wafer boxes and other material for semiconductor devices	847990
Parts of encapsulation equipment for assembly of semiconductors	847990
Parts of machines for bending, folding and straightening semiconductor leads	847990
Parts of physical deposition apparatus for semiconductor production	847990
Apparatus for rapid heating of semiconductor wafers	851430
Parts of apparatus for rapid heating of wafers	851490
Wafer probers	853690,903082
Apparatus for wet etching, developing, stripping or cleaning semiconductor wafers and flat panel displays	854330
Parts of apparatus for wet etching, developing, stripping or cleaning semiconductor wafers and flat panel displays	854390
Optical stereoscopic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles	901110
Photomicrographic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles	901120
Parts and accessories of optical stereoscopic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles	901190

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